L Number	Hits	Search Text	DB	Time stamp
1	14329	germ?nium near1 silicon	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/07/10 16:26
8	13609	SiGe GeSi (Si near1 Ge)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/07/10 16:27
15	938	Si?sub.$3 near1 Ge?sub.$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/07/10 16:28
22	25520	(germ?nium near1 silicon) (SiGe GeSi (Si near1 Ge)) (Si?sub.$3 near1 Ge?sub.$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/07/10 16:28
29	46023	silicide disilicide "TiSi.sub.2" "CoSi.sub.2"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/07/10 16:30
36	321	((germ?nium near1 silicon) (SiGe GeSi (Si near1 Ge)) (Si?sub.$3 near1 Ge?sub.$3)) near20 (silicide disilicide "TiSi.sub.2" "CoSi.sub.2")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/07/10 16:32
43	6363	((germ?nium near1 silicon) (SiGe GeSi (Si near1 Ge)) (Si?sub.$3 near1 Ge?sub.$3)) near5 (layer film interlayer interface)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/07/10 16:32
50	98	(((germ?nium near1 silicon) (SiGe GeSi (Si near1 Ge)) (Si?sub.$3 near1 Ge?sub.$3)) near5 (layer film interlayer interface)) near20 (silicide disilicide "TiSi.sub.2" "CoSi.sub.2")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/07/10 18:44
57	37	"5710450"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/07/10 18:52
64	5	"5710450" and ((germ?nium near1 silicon) (SiGe GeSi (Si near1 Ge)) (Si?sub.$3 near1 Ge?sub.$3))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/07/10 18:52
71	9	6121100.URPN.	USPAT	2002/07/10 19:07
72	3	6121100.URPN. and ((germ?nium near1 silicon) (SiGe GeSi (Si near1 Ge)) (Si?sub.$3 near1 Ge?sub.$3))	USPAT	2002/07/10 19:07

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